

☐ Method and apparatus for **cleaning** reverse-osmosis
membrane modules.

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AB The title method is characterized by using pressurized **gas** and
liq. 2 phase flow for backwashing
reverse-osmosis membrane modules. A pressurized gas is intermittently
supplied to a pressurized liq. phase flow for backwashing reverse-osmosis
membrane modules. The app. include a pressurized water supply means, and
a gas supply means for supplying a compressed gas to the pressurized water
supply means. The reverse-osmosis membrane modules are used for
desalination of seawater, etc.